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S31-0-IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re APPLICATION OF:)
Akira UDAGAWA, et al.) ATTY DKT NO. 01458.00012
SERIAL NO.: TBA) ATTN BOX PATENT
FILED: February 25, 2002) APPLICATIONS

FOR: RADIATION-MODIFIED POLY (TETRAFLUOROETHYLENE) RESIN FEEDS AND A
PROCESS FOR PRODUCING THE SAME

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

Please amend the above-identified new application as follows.

IN THE SPECIFICATION

Page 1, following the title, please add the following new paragraph;

--This application is based upon and claims the benefit of priority from Japanese Patent Application No. 2001-053495, filed February 28, 2001, the entire contents of this application are incorporated herein by reference--.

IN THE CLAIMS

Please delete Claims 6-8 and insert the following Claims therein:

- A2
- 9. The process according to claim 4, wherein the ionizing radiation is selected from electron beams, x-rays, γ -rays, neutron beams and high-energy ions which are used either independently or in admixture.
 - 10. The process according to claim 5, wherein the ionizing radiation is selected from electron beams, x-rays, γ -rays, neutron beams and high-energy ions which are used either independently or in admixture.
 - 11. The process according to claim 4, wherein the poly (tetrafluoroethylene) resin feed is in powder form.
 - 12. The process according to claim 5, wherein the poly (tetrafluoroethylene) resin feed is in powder